

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant	:	Hojo et al.
Appl. No.	:	10/553,083
Filed	:	October 11, 2005
For	:	POSITIVE RESIST COMPOSITION AND METHOD OF FORMATION OF RESIST PATTERN
Examiner	:	C. Hamilton
Group Art Unit	:	1752

AMENDMENT AND RESPONSE TO OFFICE ACTION

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Dear Sir:

In response to the Office Action mailed **January 8, 2007**, Applicants respectfully request the Examiner to enter the following amendments and consider the following remarks.

**Amendments to the Claims** are reflected in the listing of claims which begins on page 2 of this paper.

**Remarks** begin on page 5 of this paper.